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Journal Publications:

- 1. M. Venkatesh, M. Suguna, and **N.B.Balamurugan**, "Influence of Germanium Source Dual Halo Dual Dielectric Triple Material Surrounding Gate Tunnel FET for Improved Analog/RF Performance," Silicon, pp. 1–9, 2020.
- 2. M. Venkatesh and **N.B.Balamurugan**, "Influence of Threshold Voltage Performance Analysis on Dual Halo Gate Stacked Triple Material Dual Gate TFET for Ultra Low Power Applications," Silicon, pp. 1–13, 2020.
- 3. I. S. Arafat, **N.B.Balamurugan**, and S. B. Khan, "Influence of Temperature in Scattered SiNW MOSFET," Proceedings of the National Academy of Sciences, India Section A: Physical Sciences, vol. 89, no. 1, pp. 35–40, 2019.
- 4. G. Lakshmi Priya and **N.B.Balamurugan**, "New dual material double gate junctionless tunnel FET: Subthreshold modeling and simulation," AEU-International Journal of Electronics and Communications, vol. 99, pp. 130–138, 2019.
- 5. B. Buvaneswari and **N.B.Balamurugan**, "2D analytical modeling and simulation of dual material DG MOSFET for biosensing application," AEU-International Journal of Electronics and Communications, vol. 99, pp. 193–200, 2019.
- 6. B. Buvaneswari and **N.B.Balamurugan**, "Sensitivity Analysis of Double Gate Metal Oxide Semiconductor Field Effect Transistor for Bio-Sensing Applications," Journal of Nanoelectronics and Optoelectronics, vol. 14, no. 1, pp. 136–145, 2019.
- 7. K. Sowmya, **N. B. Balamurugan**, and V. Parvathy, "A 2-D Modeling of Fe doped Dual Material Gate AlGaN/AlN/GaN High Electron Mobility Transistors for High Frequency Applications," AEU-International Journal of Electronics and Communications, vol. 103, pp. 46–56, 2019.
- 8. V. Dharshana, **N. B. Balamurugan**, and T. S. Samuel, "An Analytical Modeling and Simulation of Surrounding Gate TFET with an Impact of Dual Material Gate and Stacked Oxide for Low Power Applications," Journal of Nano Research, vol. 57, pp. 68–76, 2019.

- 9. M. Venkatesh and **N. B. Balamurugan**, "New subthreshold performance analysis of germanium based dual halo gate stacked triple material surrounding gate tunnel field effect transistor," Superlattices and Microstructures, vol. 130, pp. 485–498, 2019.
- 10. M. Venkatesh, M. Suguna, and N. B. Balamurugan, "Subthreshold performance analysis of germanium source dual halo dual dielectric triple material surrounding gate tunnel field effect transistor for ultra low power applications," Journal of Electronic Materials, vol. 48, no. 10, pp. 6724–6734, 2019.
- 11. S. Manikandan, **N. B. Balamurugan**, and T. S. A. Samuel, "Impact of uniform and non-uniform doping variations for ultrathin body junctionless FinFETs," Materials Science in Semiconductor Processing, vol. 104, p. 104653, 2019.
- 12. S. Manikandan, **N. B. Balamurugan**, and D. Nirmal, "Analytical Model of Double Gate Stacked Oxide Junctionless Transistor Considering Source/Drain Depletion Effects for CMOS Low Power Applications," Silicon, pp. 1–11, 2019.
- 13. L. Priya, **N.B.Balamurugan** "Subthreshold Modeling of Triple Material Gate-All-Around Junctionless Tunnel FET with Germanium and High-K Gate Dielectric Material," Informacije MIDEM, vol. 48, no. 1, pp. 53–62, 2018.
- 14. T. V. Kumar and **N.B.Balamurugan**, "Analytical modeling of InSb/AlInSb heterostructure dual gate high electron mobility transistors," AEU-International Journal of Electronics and Communications, vol. 94, pp. 19–25, 2018.
- 15. B. Buvaneswari, **N.B.Balamurugan**, and others, "Comparative analytical analysis of various configurations of nanoscaled dielectric-modulated double gate MOSFET based biosensors," Journal of Optoelectronics and Advanced Materials, vol. 20, no. September-October 2018, pp. 526–536, 2018.
- 16. M. Jothi, **N.B.Balamurugan**, and R. H. Kumar, "Performance Analysis of Fuzzy processor for a Healthcare Application-Diabetic Epilepsy Risk Classifier," Asian Journal of Research in Social Sciences and Humanities, vol. 7, no. 2, pp. 124–140, 2017.
- 17. I. S. Arafat and **N.B.Balamurugan**, "Influence of scattering in near ballistic silicon nanowire metal-oxide-semiconductor field effect transistor," Journal of nanoscience and nanotechnology, vol. 16, no. 6, pp. 6032–6036, 2016.

- 18. P. Vanitha, G. L. Priya, **N.B.Balamurugan**, S. T. Chandra, and S. Manikandan, "Analytical Approach on the Scale Length Model for Tri-material Surrounding Gate Tunnel Field-Effect Transistors (TMSG-TFETs)," in Intelligent Computing and Applications, Springer, New Delhi, 2015, pp. 231–238.
- 19. D. Saraswathi, **N.B.Balamurugan**, G. L. Priya, and S. Manikandan, "A compact analytical model for 2D triple material surrounding gate nanowire tunnel field effect transistors," in Intelligent Computing and Applications, Springer, New Delhi, 2015, pp. 325–332.
- 20. Vimala Palanichamy and **N.B.Balamurugan**, "Comparative analysis of quantum effects in nano-scale multigate MOSFETs using variational approach," Journal of Engineering Science and Technology, vol. 10, no. 2, pp. 224–234, 2015.
- 21. S. Theodore Chandra, **N.B.Balamurugan**, G. L. Priya, V. Muralidharan, D. S. S. R. RANI, and others, "Compact modeling of gate engineered triple material gate (TMG) AlInSb/InSb high electron mobility transistors," Journal of Optoelectronics and Advanced Materials, vol. 17, no. January-February 2015, pp. 222–228, 2015.
- 22. S. Theodore Chandra, **N.B.Balamurugan**, M. Bhuvaneswari, N. Anbuselvan, and N. Mohankumar, "Analysis of charge density and Fermi level of AlInSb/InSb single-gate high electron mobility transistor," Journal of Semiconductors, vol. 36, no. 6, p. 64003, 2015.
- 23. S. Theodore Chandra, **N. B. Balamurugan**, G. L. Priya, and S. Manikandan, "Subthreshold behavior of AlInSb/InSb high electron mobility transistors," Chinese Physics B, vol. 24, no. 7, p. 76105, 2015.
- 24. G. L. Priya, **N. B. Balamurugan**, and D. Saraswathi, "Impact of Electricfield Distribution on the performance of Dual Material Gate Work function Engineered Surrounding Gate Nanowire Tunnel FETs," International Journal of Applied Engineering Research, vol. 10, no. 1, pp. 1018–1023, 2015.
- 25. P. Vanitha, **N. B. Balamurugan**, and G. L. Priya, "Triple material surrounding gate (TMSG) nanoscale tunnel FET-analytical modeling and simulation," Journal of Semiconductor Technology and science, vol. 15, no. 6, pp. 585–593, 2015.